

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

FORM PTO-1449 OCT 9 1 2005 PATENT		Docket Number (Optional) 2101-3176C1		Application Number 10/622,781	
INFORMATION DISCLOSURE CITATION IN AN APPLICATION		Applicant Young Woo Yun			
(Use several sheets if necessary)		Filing Date July 21, 2003		Group Art Unit 2133	
<b>U.S. PATENT DOCUMENTS</b>					
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS
<b>FOREIGN PATENT DOCUMENTS</b>					
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS
<b>OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)</b>					
	Siemens, "Properties of Optimised Puncturing Scheme", TSG-RAN Working Group 1 meeting No. 5, June 1-4, Cheju, Korea				
EXAMINER	Esaw Abraham	DATE CONSIDERED	12/28/05		
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